

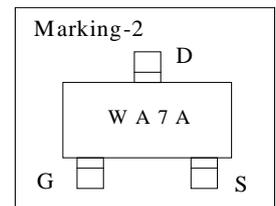
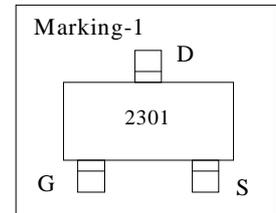
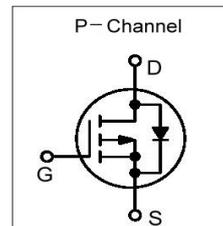
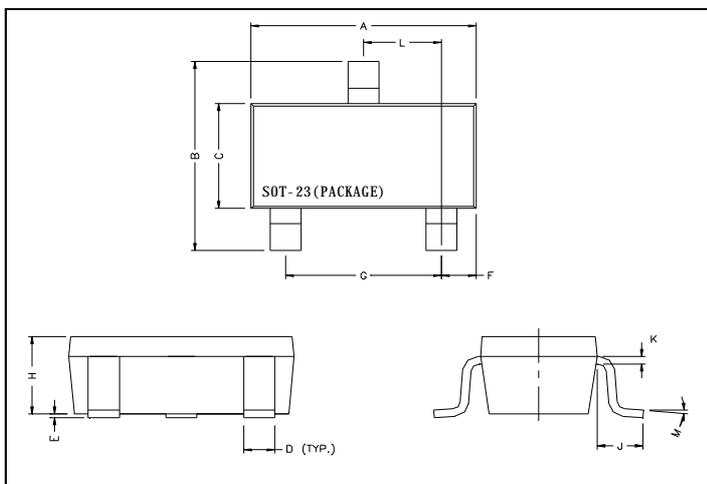
GMOS Technology Crop.

20V P-Channel Enhancement-Mode MOSFET 20V P 沟道增强型 MOS 管

VDS= -20V
RDS(ON), Vgs@-4.5V, Ids@-2.8A = 85mΩ
RDS(ON), Vgs@-2.5V, Ids@-2.0A = 110mΩ
Features 特性

Advanced trench process technology 高级的加工技术

High Density Cell Design For Ultra Low On-Resistance 极低的导通电阻高密度的单元设计

Package Dimensions 封装尺寸及外形图


| REF. | Millimeter | | REF. | Millimeter | |
|------|------------|------|------|------------|------|
| | Min. | Max. | | Min. | Max. |
| A | 2.70 | 3.10 | G | 1.90 | REF. |
| B | 2.40 | 2.80 | H | 1.00 | 1.30 |
| C | 1.40 | 1.60 | K | 0.10 | 0.20 |
| D | 0.35 | 0.50 | J | 0.40 | - |
| E | 0 | 0.10 | L | 0.85 | 1.15 |
| F | 0.45 | 0.55 | M | 0° | 10° |

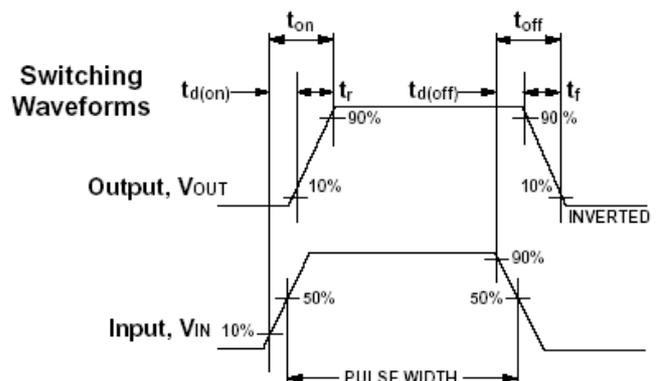
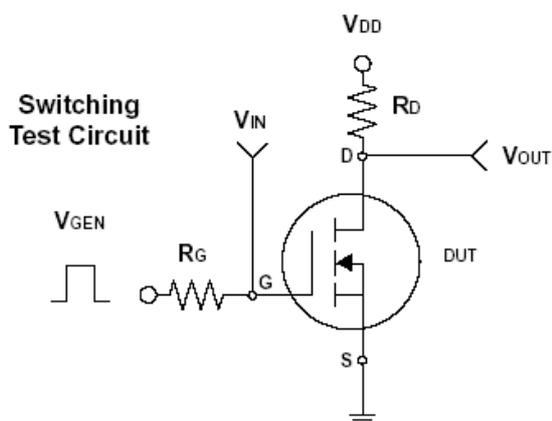
Maximum Ratings and Thermal Characteristics (TA = 25°C unless otherwise noted) 25°C 极限参数和热特性

| Parameter 极限参数 | Symbol 符号 | Limit 范围 | Unit 单位 | |
|---|-----------------------------------|------------|---------|---|
| Drain-Source Voltage 漏源电压 | V _{DS} | -20 | V | |
| Gate-Source Voltage 栅源电压 | V _{GS} | ± 12 | | |
| Continuous Drain Current 连续漏极电流 | I _D | -2.2 | A | |
| Pulsed Drain Current 脉冲漏极电流 | I _{DM} | -8 | | |
| Maximum Power Dissipation 最大耗散功率 | P _D | TA = 25°C | 1.25 | W |
| | | TA = 75°C | 0.8 | |
| Operating Junction and Storage Temperature Range 使用及储存温度 | T _J , T _{stg} | -55 to 150 | °C | |
| Junction-to-Ambient Thermal Resistance (PCB mounted) 结环热阻 | R _{θJA} | 140 | °C/W | |

GMOS Technology Crop.
ELECTRICAL CHARACTERISTICS 一般电气特性

| Parameter 参数 | 符号 | Test Condition 测试条件 | 最小值 | 典型值 | 最大值 | 单位 |
|---|--------------|---|------|------|-------|----|
| Static 静态参数 | | | | | | |
| Drain-Source Breakdown Voltage 漏源击穿电压 | BV_{DSS} | $V_{GS} = 0V, I_D = 250\mu A$ | -20 | | | V |
| Drain-Source On-State Resistance 漏源导通电阻 | $R_{DS(on)}$ | $V_{GS} = -4.5V, I_D = -2.8A$ | | 70.0 | 85.0 | mΩ |
| Drain-Source On-State Resistance 漏源导通电阻 | $R_{DS(on)}$ | $V_{GS} = -2.5V, I_D = -2.0A$ | | 85.0 | 110.0 | |
| Gate Threshold Voltage 开启电压 | $V_{GS(th)}$ | $V_{DS} = V_{GS}, I_D = 250\mu A$ | -0.4 | | -0.9 | V |
| Zero Gate Voltage Drain Current 零栅压漏极电流 | I_{DSS} | $V_{DS} = -9.6V, V_{GS} = 0V$ | | | -1 | uA |
| Gate Body Leakage 漏极短路时截止栅电流 | I_{GSS} | $V_{GS} = \pm 8V, V_{DS} = 0V$ | | | ±100 | nA |
| Forward Transconductance 正向跨导 | g_{fs} | $V_{DS} = -5V, I_D = -2.8A$ | | 6.5 | — | S |
| Dynamic 动态参数 | | | | | | |
| Total Gate Charge 栅极总电荷 | Q_g | $V_{DS} = -6V, I_D = -2.8A$ $V_{GS} = -4.5V$ | | 5.8 | 10 | nC |
| Gate-Source Charge 栅-源极电荷 | Q_{gs} | | | 0.85 | | |
| Gate-Drain Charge 栅-漏极电荷 | Q_{gd} | | | 1.7 | | |
| Turn-On Delay Time 导通延迟时间 | $t_{d(on)}$ | $V_{DD} = -6V, R_L = 6\Omega$ $I_D = -1A, V_{GEN} = -4.5V$ $R_G = 6W$ | | 13 | 25 | ns |
| Turn-On Rise Time 导通上升时间 | t_r | | | 36 | 60 | |
| Turn-Off Delay Time 关断延迟时间 | $t_{d(off)}$ | | | 42 | 70 | |
| Turn-Off Fall Time 关断下降时间 | t_f | | | 34 | 60 | |
| Input Capacitance 输入电容 | C_{iss} | $V_{DS} = -6V, V_{GS} = 0V$ $f = 1.0\text{ MHz}$ | | 415 | | pF |
| Output Capacitance 输出电容 | C_{oss} | | | 223 | | |
| Reverse Transfer Capacitance 反向传输电容 | C_{rss} | | | 87 | | |
| Source-Drain Diode 源漏二极管参数 | | | | | | |
| Max. Diode Forward Current 最大正向电流 | I_S | | | | -1.6 | A |
| Diode Forward Voltage 正向电压 | V_{SD} | $I_S = -1.6A, V_{GS} = 0V$ | | | -1.2 | V |

Note: Pulse test: pulse width $\leq 300\mu s$, duty cycle $\leq 2\%$ 注意: 脉冲测试: 脉冲宽度 $\leq 300\mu s$ 死区 $\leq 2\%$



GMOS Technology Crop.

Characteristics Curve 电气性能特征曲线

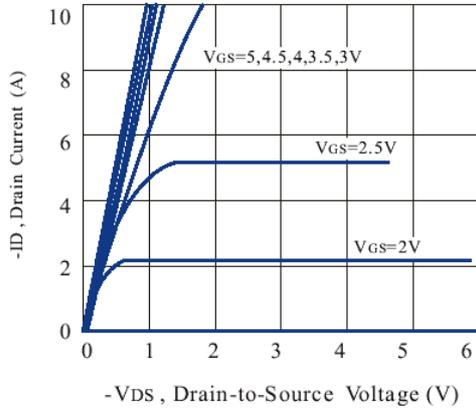
P-Channel Enhancement Mode MOSFET


Figure 1. Output Characteristics

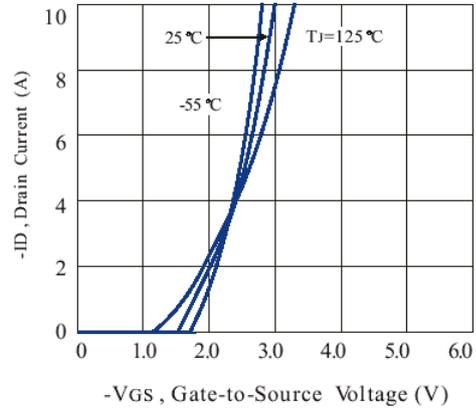


Figure 2. Transfer Characteristics

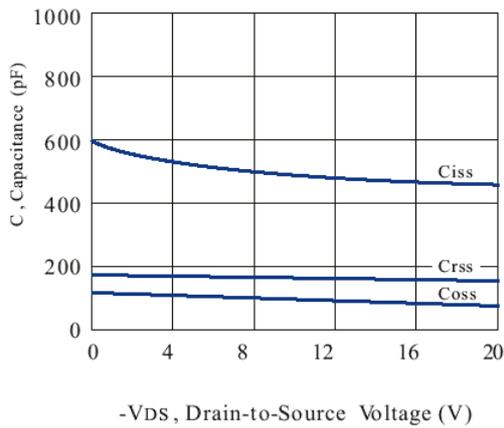


Figure 3. Capacitance

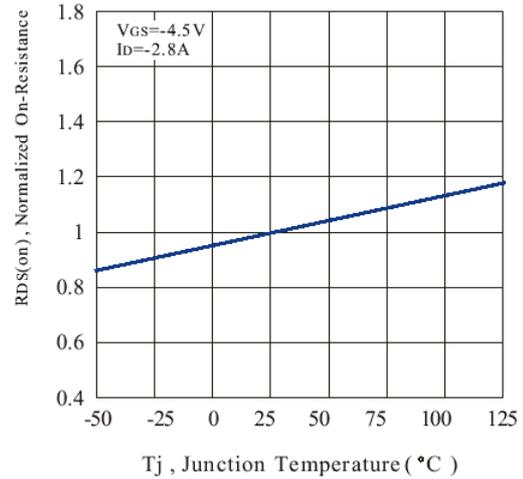


Figure 4. On-Resistance Variation with Temperature

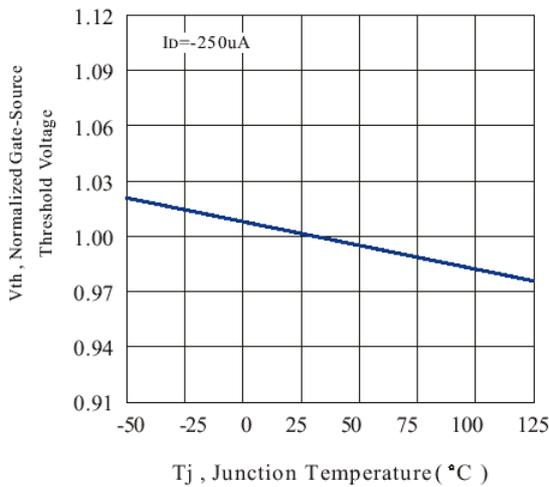


Figure 5. Gate Threshold Variation with Temperature

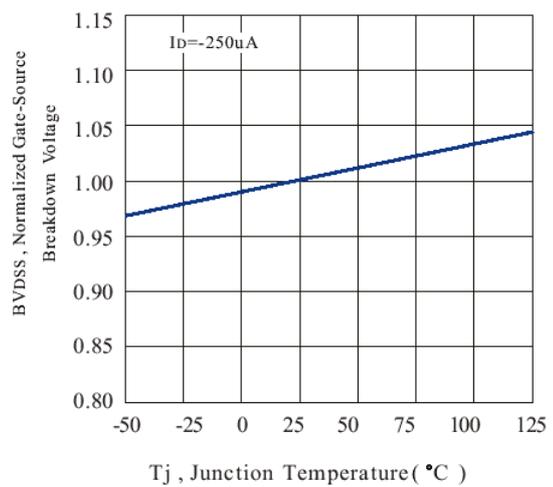


Figure 4. Breakdown Voltage with Temperature